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List of Publications by Year in descending order

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623734 677142 40 520 14 22 g-index citations h-index papers 40 40 40 682 docs citations times ranked citing authors all docs

#	Article	IF	Citations
1	Effect of HTL thickness on air processed CVD perovskite solar cells. Materials Today: Proceedings, 2021, 36, 303-308.	1.8	2
2	Mixed-halide perovskites solar cells through PbICl and PbCl2 precursor films by sequential chemical vapor deposition. Solar Energy, 2021, 215, 179-188.	6.1	14
3	Controlled Deposition of Lead Iodide and Lead Chloride Thin Films by Low-Pressure Chemical Vapor Deposition. Coatings, 2020, 10, 1208.	2.6	3
4	Air-Stable Hybrid Perovskite Solar Cell by Sequential Vapor Deposition in a Single Reactor. ACS Applied Energy Materials, 2020, 3, 2350-2359.	5.1	30
5	Adsorption of phosphoric acid anions on platinum (111). Adsorption, 2017, 23, 971-981.	3.0	3
6	Chemical, electronic and nanostructural properties of nanocrystalline silicon synthesised by hotâ€wire CVD. Physica Status Solidi (A) Applications and Materials Science, 2016, 213, 1705-1709.	1.8	1
7	Oxidation Reduction in Nanocrystalline Silicon Grown by Hydrogen-Profiling Technique. Journal of Nano Research, 2016, 41, 9-17.	0.8	1
8	Effect of additional electron acceptor in hybrid P3HT:PCBM:ZnO spin oated films for photovoltaic application. Physica Status Solidi (A) Applications and Materials Science, 2016, 213, 1915-1921.	1.8	5
9	Structural and optical characterization of mechanically milled Mg-TiO2 and nitrided Mg-TiO -N nanostructures: Possible candidates for gas sensing application. Applied Surface Science, 2016, 360, 1047-1058.	6.1	3
10	Investigation of isochronal annealing on the optical properties of HWCVD amorphous silicon nitride deposited at low temperatures and low gas flow rates. Journal of Physics: Conference Series, 2015, 619, 012014.	0.4	0
11	Depth-dependent crystallinity of nano-crystalline silicon induced by step-wise variation of hydrogen dilution during hot-wire CVD. Journal of Physics: Conference Series, 2015, 619, 012002.	0.4	0
12	Degradation of a tantalum filament during the hot-wire CVD of silicon nitride thin films. Thin Solid Films, 2015, 575, 42-46.	1.8	0
13	Formation of the metastable FCC phase by ball milling and annealing of titanium–stearic acid powder. Advanced Powder Technology, 2015, 26, 632-639.	4.1	23
14	Formation of face-centered cubic and tetragonal titanium oxynitride by low temperature annealing of ball milled titanium powder in air. Advanced Powder Technology, 2015, 26, 169-174.	4.1	4
15	Characteristics of the mechanical milling on the room temperature ferromagnetism and sensing properties of TiO2 nanoparticles. Applied Surface Science, 2015, 331, 362-372.	6.1	42
16	Investigation of the growth and local stoichiometric point group symmetry of titania nanotubes during potentiostatic anodization of titanium in phosphate electrolytes. Journal of Physics and Chemistry of Solids, 2015, 85, 278-286.	4.0	6
17	Structure–property analysis of the Mg–TiO2 and Mg–Sn–TiO2 composites intended for biomedical application. Materials Letters, 2015, 161, 328-331.	2.6	2
18	Morphology and structural development of reduced anatase-TiO2 by pure Ti powder upon annealing and nitridation: Synthesis of TiOx and TiOxNy powders. Materials Characterization, 2015, 100, 41-49.	4.4	26

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19	Microstructural, optical properties and thermal stability of MgO/Zr/MgO multilayered selective solar absorber coatings. Solar Energy, 2015, 111, 357-363.	6.1	52
20	Production of titanium–tin alloy powder by ball milling: Formation of titanium–tin oxynitride composite powder produced by annealing in air. Journal of Alloys and Compounds, 2015, 622, 824-830.	5.5	7
21	Femtosecond laser surface structuring and oxidation of chromium thin coatings: Black chromium. Applied Surface Science, 2014, 321, 560-565.	6.1	28
22	Microstructure and phase transformation on milled and unmilled Ti induced by water quenching. Materials Letters, 2014, 132, 157-161.	2.6	27
23	Thermal stability of electron beam evaporated AlxOy/Pt/AlxOy multilayer solar absorber coatings. Solar Energy Materials and Solar Cells, 2014, 120, 473-480.	6.2	53
24	The influence of ZnO nanostructures on the structure, optical and photovoltaic properties of organic materials. Thin Solid Films, 2014, 555, 100-106.	1.8	11
25	Characterization of silicon nitride thin films deposited by hot-wire CVD at low gas flow rates. Applied Surface Science, 2013, 285, 440-449.	6.1	23
26	Comparative study: the effect of annealing conditions on the properties of P3HT:PCBM blends. Journal of Materials Science, 2013, 48, 1763-1778.	3.7	32
27	Structural and optical properties of AlxOy/Pt/AlxOy multilayer absorber. Materials Science and Engineering B: Solid-State Materials for Advanced Technology, 2012, 177, 1194-1199.	3.5	25
28	Spectroscopy and structural properties of amorphous and nanocrystalline silicon carbide thin films. Physica Status Solidi C: Current Topics in Solid State Physics, 2011, 8, 2661-2664.	0.8	1
29	Thermal annealing of protocrystalline a-Si:H. Thin Solid Films, 2011, 519, 4462-4465.	1.8	3
30	Growth kinetics of nc-Si:H deposited at $200 \hat{A}^{\circ} \text{C}$ by hot-wire chemical vapour deposition. Thin Solid Films, $2011, 519, 4437-4441$.	1.8	7
31	Employing the effective medium approximation to model the optical properties of crystallized a-Si:H obtained by MIC. Physica Status Solidi C: Current Topics in Solid State Physics, 2010, 7, NA-NA.	0.8	2
32	Dual Catalytic Purpose of the Tungsten Filament During the Synthesis of Single-Helix Carbon Microcoils by Hot-Wire CVD. Journal of Nanoscience and Nanotechnology, 2009, 9, 5870-5873.	0.9	1
33	Filament poisoning at typical carbon nanotube deposition conditions by hot-filament CVD. Journal of Materials Science, 2009, 44, 2610-2616.	3.7	10
34	Thermal stability of the optical band gap and structural order in hot-wire-deposited amorphous silicon. Journal of Materials Science, 2009, 44, 6333-6337.	3.7	2
35	Thermally Induced Nano-Structural and Optical Changes of nc-Si:H Deposited by Hot-Wire CVD. Nanoscale Research Letters, 2009, 4, 307-312.	5.7	18
36	Extension of the lifetime of tantalum filaments in the hot-wire (Cat) Chemical Vapor Deposition process. Thin Solid Films, 2008, 516, 822-825.	1.8	21

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37	Improved stability of intrinsic nanocrystalline Si thin films deposited by hot-wire chemical vapour deposition technique. Thin Solid Films, 2007, 515, 8040-8044.	1.8	16
38	Optical characterisation of a-Si:H and nc-Si:H thin films using the transmission spectrum alone. Journal of Materials Science: Materials in Electronics, 2007, 18, 225-229.	2.2	6
39	Crystallization of HWCVD amorphous silicon thin films at elevated temperatures. Thin Solid Films, 2006, 501, 98-101.	1.8	9
40	Amorphous and nc-Si:H Intrinsic Thin Films for Solar Cells Applications. Materials Science Forum, 0, 657, 191-207.	0.3	1